

PATENT
0941-0867P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: CHANG, Ching-Yu Conf.:
Appl. No.: NEW Group:
Filed: November 19, 2003 Examiner:
For: METHOD OF FORMING A DUAL-LAYER RESIST AND
 APPLICATION THEREOF

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

November 19, 2003

Sir:

The following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application.

This amendment includes:

Amendments to the Specification

Remarks